

Attorney's Docket 040258-0280043  
Client Reference: EL00026CDC

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Re PATENT APPLICATION of:  
TADAHIRO OHMI ET AL.

Confirmation Number: 4153

Application No.: 09/827,307

Group Art Unit: 1763

Filed: April 6, 2001

Examiner: L. Alehandro Mulero

For: PLASMA PROCESSING APPARATUS AND PLASMA PROCESSING METHOD

**Commissioner for Patents**  
**P.O. Box 1450**  
**Alexandria, VA 22313-1450**

**AMENDMENT/RESPONSE TRANSMITTAL**

Transmitted herewith is an amendment/response for this application.

**FEES**

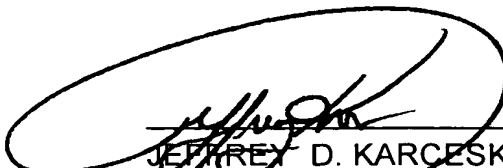
The fee for claims and extension of time (37 C.F.R. 1.16 and 1.17) has been calculated as shown below:

	CLAIMS REMAINING AFTER AMENDMENT	HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDIT. FEE
TOTAL	12	- 20	= 0	x \$ 18.00	= \$ 0.00
INDEP.	3	- 3	= 0	x \$ 86.00	= \$ 0.00
FIRST PRESENTATION OF MULTIPLE DEP. CLAIM				+ \$ 290.00	= \$ 0.00
TOTAL ADDITIONAL CLAIM FEE					\$ 0.00
GRAND TOTAL					\$ 0.00

**FEE PAYMENT**

Authorization is hereby made to charge the amount of \$0.00 to Deposit Account No. 033975. Charge any additional fees required by this paper or credit any overpayment in the manner authorized above. A duplicate of this paper is attached.

Date: June 3, 2004  
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JEFFREY D. KARCZESKI  
Reg. No. 35914



Corres. and Mail  
**BOX AF**

REPLY UNDER 37 C.F.R. § 1.116  
EXPEDITED PROCEDURE  
TECHNOLOGY CENTER ART UNIT 1763

JTW  
1763  
AF

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Confirmation No.: 4153

**OHMI et al.**

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Title: PLASMA PROCESSING APPARATUS AND PLASMA PROCESSING METHOD

June 3, 2004

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**RESPONSE UNDER 37 C.F.R. § 1.116**

Mail Stop AF  
Hon. Commissioner of Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Final Office Action, mailed March 17, 2004, the date for response to which is June 17, 2004, reconsideration and allowance of the present application based on the following remarks is respectfully requested.